

## A theoretical study of surface reconstructed silicon nanowires

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### Abstract

One-dimensional nanostructures are attracting a great interest for their potentially high impact in future molecular electronics applications, such as nanoswitches and nanocontacts.

Silicon nanowires (SiNWs) appear to be a special appealing alternative, due to the ideal interface compatibility with conventional Si-based technology and to the possibility to tune their conductive properties by means of electrical doping.

While it has been extensively demonstrated that in H-terminated SiNWs quantum confinement induces a gap-broadening effect<sup>1</sup>, very little is known about surface reconstruction of non-passivate wires and their electronic structure features. We present a theoretical study based on density-functional calculations of realistic  $\langle 100 \rangle$  SiNWs<sup>2</sup>, with a bulk Si core and a diameter of  $\sim 1.5$  nm. Particularly, we focus our attention on the features of the electronic properties of the wire as determined by the different possible lateral surface reconstruction. We find two competing geometries for the  $\{100\}$  facets. One of them shows a semi-metallic behavior with one state approaching the Fermi level at the zone boundary, while the other has four metallic states. These states show a great degree of surface localization. Therefore, current flow is almost entirely sustained by the outer layers of the SiNW<sup>3</sup>.

The possibility to obtain one-dimensional metallic Si nanostructures opens up the way to a wide range of novel nanoscience applications that require stout and atomic-scale contacts. Metallic SiNWs are a promising path to usher Si in nanotechnology applications.

Preliminary results of non-equilibrium electron transport calculations will also be presented<sup>4</sup>.

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- <sup>1</sup> B. Delley and E. F. Steigmeier, *Appl. Phys. Lett.*, **67**, 2370 (1995).
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  - <sup>4</sup> M. Brandbyge, J.-L. Mozos, P. Ordejón, J. Taylor, and K. Stokbro, *Phys. Rev. B* **65**, 165401 (2002).